

## SDAŃSK UNIVERSITY 的 OF TECHNOLOGY

## Subject card

Subject name and code	Diffraction methods of structural analysis, PG_00058968									
Field of study	Nanotechnology									
Date of commencement of studies	October 2022		Academic year of realisation of subject			2024/2025				
Education level	first-cycle studies		Subject group							
Mode of study	Full-time studies		Mode of delivery			at the university				
Year of study	3		Language of instruction			Polish				
Semester of study	5		ECTS credits			4.0				
Learning profile	general academic profile		Assessment form			assessment				
Conducting unit	Department of Solid State Physics -> Faculty of Applied Physics and Mathematics									
Name and surname	Subject supervisor		prof. dr hab. inż. Tomasz Klimczuk							
of lecturer (lecturers)	Teachers		prof. dr hab. inż. Tomasz Klimczuk							
Lesson types and methods of instruction	Lesson type	/pe Lecture		Laboratory Projec		t	Seminar	SUM		
	Number of study hours	15.0	0.0	30.0	0.0		0.0	45		
	E-learning hours included: 0.0									
Learning activity and number of study hours	Learning activity	Participation in classes includ plan	n didactic ed in study	Participation in consultation hours		Self-study		SUM		
	Number of study hours	45		0.0		0.0		45		
Subject objectives	The aim of the course is to train students with the various diffraction methods and computer tools for analysis xrd data and visualization of crystal structures.									
Learning outcomes	Course outcome Subject outcome Method of verification									
	K6_K05		The student critically evaluates his own performance, constructively evaluates the results of the work of others.			[SK2] Assessment of progress of work				
	K6_W07	The student is an expert in the physical and chemical basis of nanotechnology.			[SW2] Assessment of knowledge contained in presentation					
	K6_U06	The student accurately, clearly but not oversimplified, explains even the most intricate technological and scientific problems related to the manufacture and applications of nanostructures.			[SU2] Assessment of ability to analyse information					
Subject contents	 				I					
	1. Introduction to the course. (2 hours)2. Diffraction methods. (4 hours)3. Introduction to Database ICSD / FindIt and CoD. Simulations using PowderCell. (2 hours)4. Visualization of crystal structures using VESTA. (4 hours)5. Introduction to the Rietveld method and LeBail. (2 hours)6. Mathematical basis of the Rietveld method. (2 hours)7. Package FullProf Suite. (6 hours)8. Neutron diffraction methods. (4 hours)9. Practical aspects of measurements of neutron and synchrotron (infrastructure, applying for beamtime, sample preparation, etc.). (2 hours)10. The future of diffraction methods. (2 hours)									
Prerequisites and co-requisites	Basic knowledge in crystallography.									
Assessment methods and criteria	Subject passin	g criteria	Passing threshold			Percentage of the final grade				
	Final test		60.0%			60.0%				
	Practical test		60.0%			40.0%				

Recommended reading	Basic literature		FullProf manual: https://www.psi.ch/sinq/dmc/ManualsEN/ fullprof.pdf				
			. L.B. McCusker, et al. <i>Rietveld refinement guidelines</i> , J. Appl. Cryst. (1999) vol. 32, 36-50				
			B. H. Toby, <i>R-factors: how good is good enough?</i> , Powder Diffraction (2006) vol. 21, 67-70				
			D. S. Sivia, <i>Elementary Scattering Theory For X-ray and Neutron Users</i> , Oxford University Press (2014)				
		5.	H. M. Rietveld, A profile refinement method for nuclear and magnetic structures, Journal of Applied Crystallography (1969) vol. 2, 65-71 http://epswww.unm.edu/media/pdf/Rietveld-1969-ProfileRefinement.pdf				
	Supplementary literature	1.	G. Will, Powder Diffraction: The Rietveld Method and the Two Stage Method to Determine and Refine Crystal Structures from Powder Diffraction Data, Springer (2006) http://link.springer.com/ book/10.1007/3-540-27986-5				
	eResources addresses		Adresy na platformie eNauczanie:				
Example issues/ example questions/ tasks being completed	Using Vesta software draw and then discuss the details of the structure of Mg10Ir19B16 compound.						
Work placement	Not applicable						